

IN THE SPECIFICATION:

Please amend the following portions of the application as indicated:

Please amend page 1, lines 9-28 as follows:

It is known to use documents having position identification markings in combination with a pattern reading device such as a digital pen. The device may have an imaging system, such as an ~~infra-red~~ infrared camera, within it, which is arranged to image a small area of the page close to the pen nib. The pen includes a processor having image processing capabilities and a memory and is triggered by a force sensor in the nib to record images from the camera as the pen is moved across the document. From these images the pen can determine the position of any marks made on the document by the pen. The pen markings can be stored directly as graphic images, which can then be stored and displayed in combination with other markings on the document. In some applications the simple recognition that a mark has been made by the pen on a predefined area of the document can be recorded, and this information used in any suitable way. This allows, for example, forms with check boxes on to be provided and the marking of the check boxes with the pen to be detected. In further applications the pen markings are analysed using character recognition tools and stored digitally as text. Systems using this technology are available from Anoto AB and described on their website www.Anoto.com.

Further, please amend page 13, lines 13-24 as follows:

The pattern areas 107 have respective positions within the total pattern space area allocated to them. These allocated positions within the total pattern space are requested from, and allocated by, a pattern allocating server. Referring to FIG. 5, a single page 700 of pattern space required for the document 100 can be broken down by the FDT into a number of separate pattern space areas 718, 720, 721, 722. These pattern space areas ~~[[728]]~~ 718, 720, 721, 722 are to be allocated to the respective boxes 118, 120, 121, 122 on the document 100 (Step 606). These pattern space areas 718, 720, 721, 722 are arranged on the page 700 of pattern space in any suitable way. In particular, the relative positions of the pattern space areas 718, 720, 721, 722 on the pattern space page 700 can differ from their relative positions on the final document 100.

Finally, please amend page 15, lines 4-8 as follows:

Also as shown in FIG. ~~[[8]]~~ 6, the file may contain other, optional, features. For example, the file 800 may also contain information relating to the functions (if any) associated with the pattern areas on the document 100 and the relative positions of the pattern areas within the pattern space page 700 allocated to the document 100.